



Docket No.: M4065.0488/P488
(PATENT)

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of:
John Moore, et al

Confirmation No.: 2073

Application No.: 10/035,197

Group Art Unit: 2185

Filed: January 4, 2002

Examiner: Not Yet Assigned

For: PCRAM REWRITE PREVENTION

INFORMATION DISCLOSURE STATEMENT (IDS)

Commissioner for Patents
Washington, DC 20231

Dear Sir:

Pursuant to 37 CFR 1.56, the attention of the Patent and Trademark Office is hereby directed to the references listed on the attached PTO/SB/08. It is respectfully requested that the information be expressly considered during the prosecution of this application, and that the references be made of record therein and appear among the "References Cited" on any patent to issue therefrom.

This Information Disclosure Statement is filed before the mailing date of a first Office Action on the merits as far as is known to the undersigned.

A copy of each reference on PTO/SB/08 is attached.

A concise explanation of relevance of the items listed on form PTO/SB/08 is:

☒ not given

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☐ given for only non-English language listed items

[] in the form of an English language copy of a Search Report from a foreign patent office, issued in a counterpart application, which refers to the relevant portions of the references

While the information and references disclosed in this Information Disclosure Statement may be "material" pursuant to 37 CFR 1.56, it is not intended to constitute an admission that any patent, publication or other information referred to therein is "prior art" for this invention unless specifically designated as such.

In accordance with 37 CFR 1.97(g), the filing of this Information Disclosure Statement shall not be construed to mean that a search has been made or that no other material information as defined in 37 CFR 1.56(a) exists. It is submitted that the Information Disclosure Statement is in compliance with 37 CFR 1.98 and the Examiner is respectfully requested to consider the listed references.

The Commissioner is hereby authorized to charge any deficiency in the fees filed, asserted to be filed or which should have been filed herewith (or with any paper hereafter filed in this application by this firm) to our Deposit Account No. 04-1073, under Order No. M4065.0488/P488. A duplicate copy of this paper is enclosed.

Dated: April 17²⁷, 2003

Respectfully submitted,

By 

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Atty Docket No.: M4065.0488/P488 ✓

Application No.: 10/035,197-Conf. #2073
Title: PCRAM REWRITE PREVENTION

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Documents Filed:

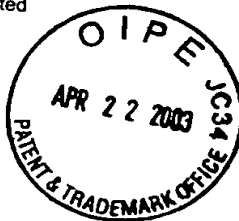
Transmittal (1 page)

Information Disclosure Statement (2 pages in duplicate)

PTO SB/08 (4 pages) with references cited

Via: PTO Daily Run

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Date: April 22, 2003

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PTO/SB/08A (10-01)

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U. S. Patent and Trademark Office: U. S. DEPARTMENT OF COMMERCE

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Substitute for form 1449A/PTO INFORMATION DISCLOSURE STATEMENT BY APPLICANT <i>(use as many sheets as necessary)</i>				Complete if Known	
				Application Number	10/035,197
				Filing Date	January 4, 2002
				First Named Inventor	John Moore
				Art Unit	2185
				Examiner Name	Not Yet Assigned
Sheet	1	of	4	Attorney Docket Number	M4065.0488/P488

U.S. PATENT DOCUMENTS					
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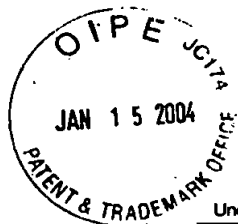
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				Application Number	10/035,197
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				First Named Inventor	John Moore
				Art Unit	2185
				Examiner Name	Not Yet Assigned
Sheet	2	of	4	Attorney Docket Number	M4065.0488/P488

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FOREIGN PATENT DOCUMENTS						
Examiner Initials*	Cite No. ¹	Foreign Patent Document	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear	T ⁶
		Country Code ² -Number ³ -Kind Code ⁴ (if known)				
	BA	JP 56126916	10/1981	Akira et al.		
	BB					

Examiner Signature		Date Considered	
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Substitute for form 1449B/PTO INFORMATION DISCLOSURE STATEMENT BY APPLICANT (use as many sheets as necessary)		Complete if Known			
		Application Number	10/193,529		
		Filing Date	July 10, 2002		
		First Named Inventor	Kristy A. Campbell		
		Group Art Unit	2714		
		Examiner Name	H. Weiss		
Sheet	4	of	4	Attorney Docket Number	M4065.0695/P695

OTHER PRIOR ART – NON PATENT LITERATURE DOCUMENTS			
Examiner Initials	Cite No. ¹	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc), date, page(s), volume-issue number(s), publisher, city and/or country where published.	T ²
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	CP		
	CQ		

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